

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the application of: Anthony *et al.*

Docket: TI-24953

Serial No.: 09/116,138

Examiner: B. Su

Filed: 07/15/98

Art Unit: 2814

For: High Permittivity Silicate Gate Dielectric

#10 (Ex. 10)  
Time (1)  
TJ 1/22/99  
B-22-99

## Petition For Extension of Time Under 37 C.F.R. § 1.136

December 20, 1999

Assistant Commissioner For Patents  
Washington, D. C. 20231

FACSIMILE CERTIFICATE  
I hereby certify that this correspondence is being transmitted by Facsimile to the Patent and Trademark Office in accordance with 37 C.F.R. §1.6d on December 20, 1999.



David Denker, Reg. No. 40,987

Dear Sir:

Pursuant to 37 C.F.R. 1.136(a) Applicants respectfully petition the Commissioner for a one month extension of the shortened statutory period for response in the above-identified application.

Please charge this and any other required fee to the deposit account of Texas Instruments Incorporated, Account No. 20-0668. Any further necessary extension of time is hereby requested.

Respectfully submitted,


David Denker  
Reg. No. 40,987

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